



DPW

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

APPLICANT: Min-Chul Sun **DOCKET NO.** 8021-160 (SS-18118-US)
SERIAL NO: 10/621,292 **GROUP:** Art Unit 2823
FILED: July 17, 2003 **EXAMINER:** Pham, Thanh V.
FOR: **METHOD FOR FABRICATING SEMICONDUCTOR DEVICE
USING A NICKEL SALICIDE PROCESS**

Mail Stop Amendment
Commissioner for Patents
PO Box 1450
Alexandria VA 22313-1450

RESPONSE TO RESTRICTION REQUIREMENT

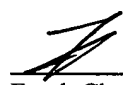
Sir:

In response to the Office Action dated December 15, 2004, applicant provisionally elects the claims of Group I (claims 1-8 and 12-18), with traverse. While the device of Group I and the method of Group II may be distinct for the reasons set forth by the Examiner, applicant believes that simultaneous examination will not present an undue burden. For example, the claims of Group I are drawn to a non-volatile memory cell and the claims of Group II are drawn to a method of forming a non-volatile memory cell. Indeed, the subject matter in the claims of both Groups can be commonly found in class 257.

CERTIFICATE OF MAILING UNDER 37 C.F.R. §1.8(a)

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail, postpaid in an envelope, addressed to the: Mail Stop Amendment, Commissioner for Patents, PO Box 1450, Alexandria, VA22313-1450 on January 6, 2005.


Dated: 1/6/05


Frank Chau

Under such circumstances, the Examiner is encouraged to maintain all claims in the same application. See, MPEP § 803.

Early and favorable consideration of this application are earnestly solicited.

Respectfully submitted,


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